



INFORMATION DISCLOSURE CITATION

(use several sheets if necessary)

MAR 22 2006

Docket Number (Optional)

Beaumont-12

Application Number

10/518,724

Applicant(s)

Lavallee et al.

Filing Date

December 20, 2004

Group Art Unit

2882

U.S. PATENT DOCUMENTS

| *EXAMINER INITIAL | REF | DOCUMENT NUMBER | DATE | NAME | CLASS | SUBCLASS | FILING DATE IF APPROPRIATE |
|-------------------|-----|-----------------|----------|---------------------|-------|----------|----------------------------|
| /LNL/ | | 5,836,954 | 11/17/98 | Heilbrun et al. | | | |
| /LNL/ | | 6,006,127 | 12/21/99 | Van Der Brug et al. | | | |
| /LNL/ | | 6,074,394 | 06/13/00 | Krause | | | |
| /LNL/ | | 6,285,902 B1 | 09/04/01 | Kienzle, III et al. | | | |
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U.S. PATENT APPLICATION PUBLICATIONS

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FOREIGN PATENT DOCUMENTS

| REF | DOCUMENT NUMBER | DATE | COUNTRY | CLASS | SUBCLASS | Translation | |
|-------|-----------------|----------|---------|-------|----------|-------------|----|
| | | | | | | YES | NO |
| /LNL/ | WO 00/48507 | 08/24/00 | PCT | | | | |
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OTHER DOCUMENTS *(Including Author, Title, Date, Pertinent Pages, Etc.)*

| | | |
|-------|--|--|
| /LNL/ | | International Search Report dated November 17, 2003 for related PCT Application No. PCT/FR03/01917 |
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EXAMINER /Lawrence Laryea/

DATE CONSIDERED

08/19/2008

EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP Section 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.